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CONTENTS

Transient global modeling of oxygen and carbon segregations during the pulling process of Czochralski silicon crystal growth By Xin LIU, Hirofumi HARADA, Yoshiji MIYAMURA, Xue-Feng HAN, Satoshi NAKANO, Shin-ichi NISHIZAWA, and Koichi KAKIMOTO.....	1
3D Numerical Study of Crystal Rotation Effect on Three-Phase Line in Floating Zone Silicon By Xue-Feng HAN, Xin LIU, Satoshi NAKANO, Hirofumi HARADA, Yoshiji MIYAMURA, and Koichi KAKIMOTO.....	7
Impact of applying tidal correction to marginal-sea bathymetry dataset By Katsuto UEHARA	12